Fig.1

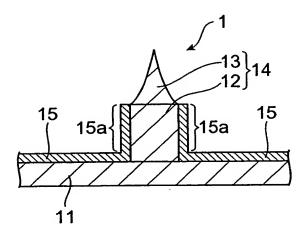
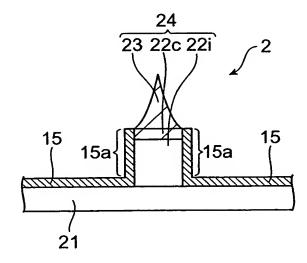


Fig.2



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Fig.3

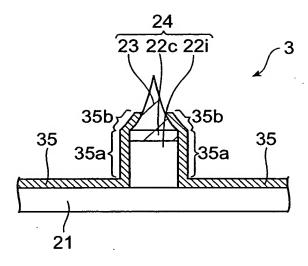
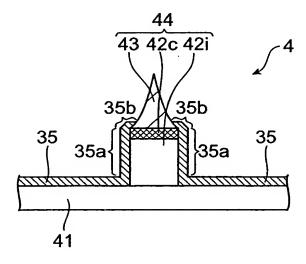
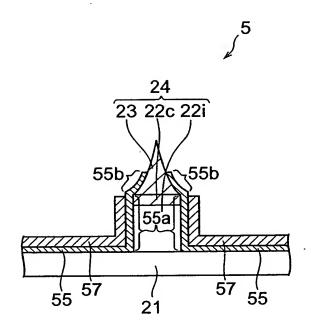


Fig.4



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Fig.5



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Fig.6A

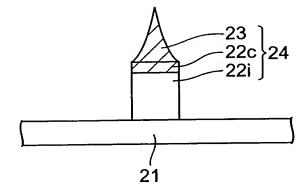


Fig.6B

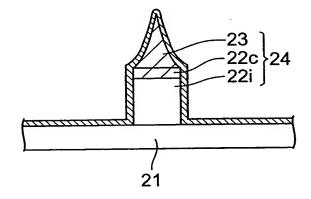


Fig.6C

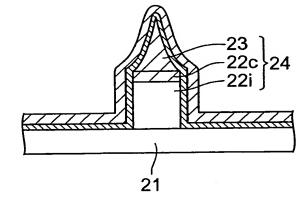


Fig.7A

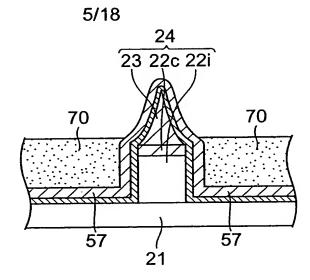


Fig.7B

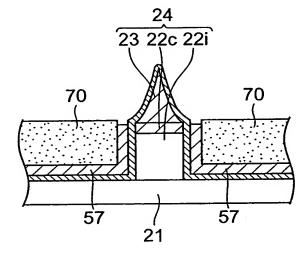
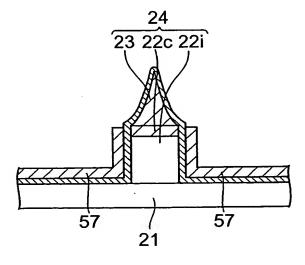


Fig.7C



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Fig.8A

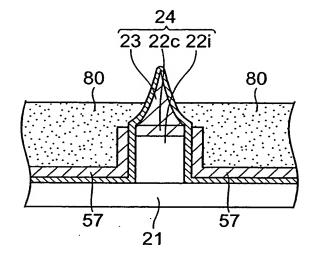


Fig.8B

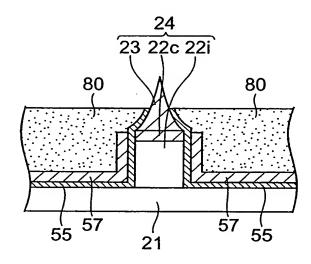
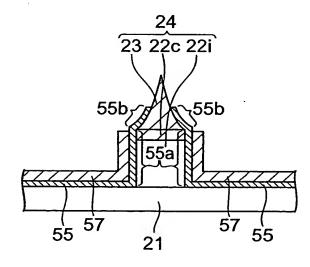


Fig.8C



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Fig.9A

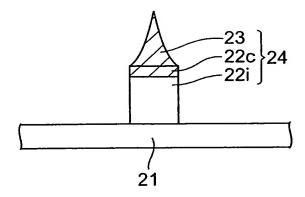


Fig.9B

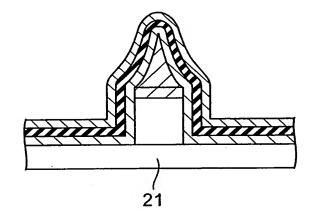
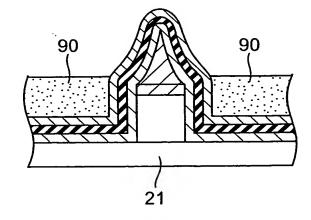
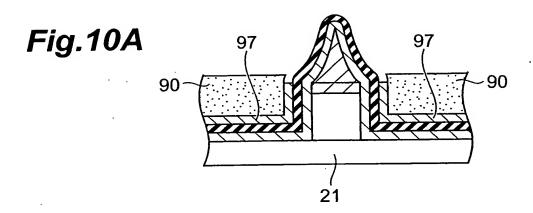
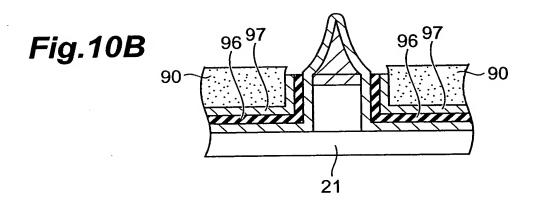


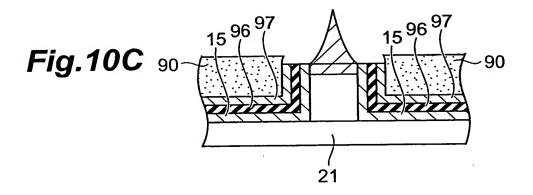
Fig.9C



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Fig.11

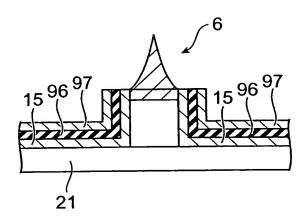


Fig.12

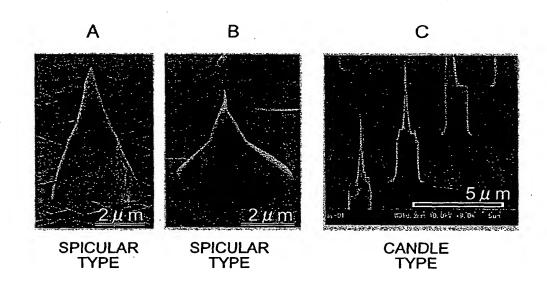


Fig.13

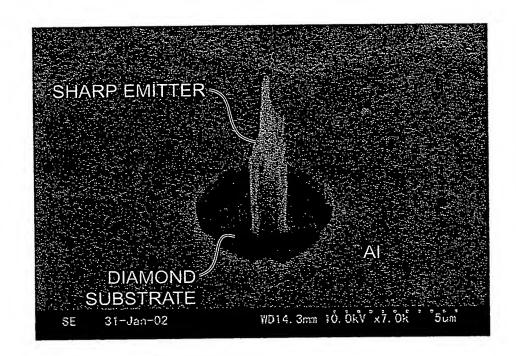
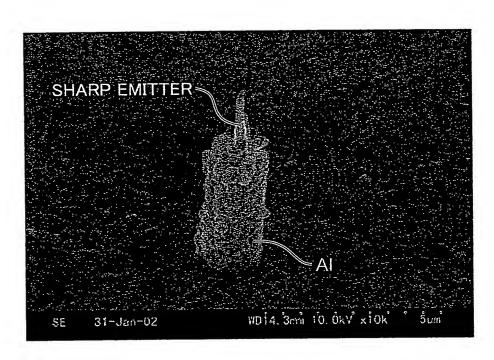
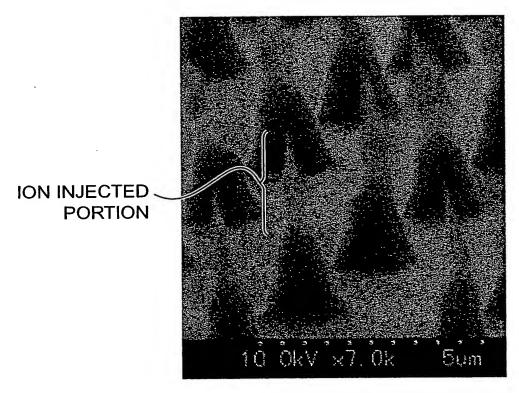


Fig.14



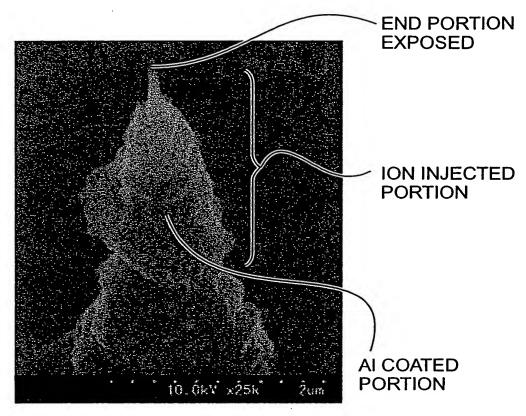
SHARP EMITTER WITH AN AL ELECTRODE

Fig.15



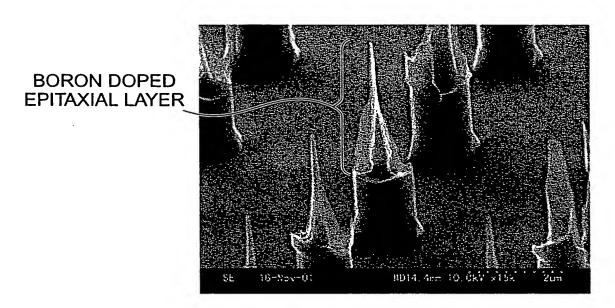
SHARP EMITTER
WITH AN AI ION INJECTED LAYER

Fig.16



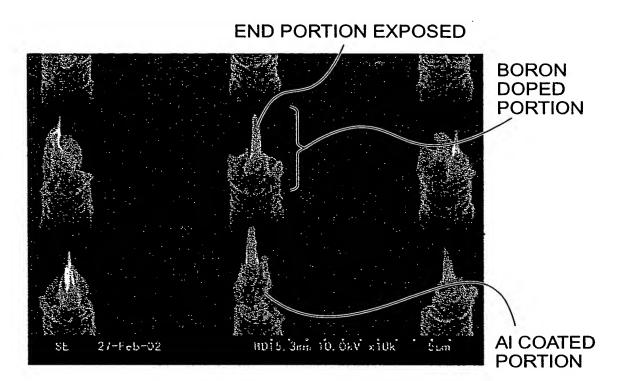
PROTRUSION WHERE AN AI ELECTRODE IS FORMED EXCEPT FOR THE TIP

Fig.17



SHARP EMITTER INCLUDING A BORON DOPED EPITAXIAL LAYER

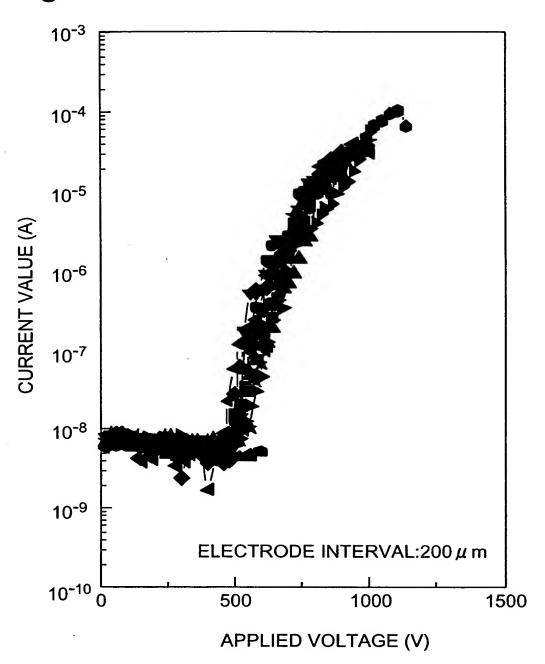
Fig.18



PROTRUSION WHERE AN AL ELECTRODE IS FORMED EXCEPT FOR THE END PORTION

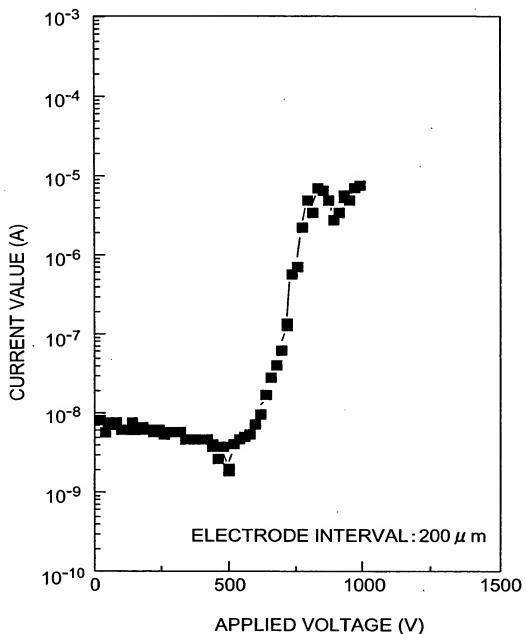
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Fig.19



ELECTRON EMISSION CHARACTERISTIC
OF A SHARP EMITTER INCLUDING
AN AI ION INJECTED LAYER
AND BEING PLOVIDED WITH AN AI ELECTRODE





ELECTRON EMISSION CHARACTERISTIC
OF A SHARP EMITTER INCLUDING
A BORON DOPED EXITAXIAL LAYER
AND BEING PROVIDED WITH AN AL ELECTRODE